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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/624,357	07/21/2003	Aaron Scott Lukas	06381P USA	7231	
23543	7590 01/06/2006		EXAM	EXAMINER	
	JCTS AND CHEMIC	BLUM, E	BLUM, DAVID S		
PATENT DE 7201 HAMIL	PARTMENT TON BOULEVARD		ART UNIT	PAPER NUMBER	
ALLENTOWN, PA 181951501			2813		

DATE MAILED: 01/06/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

-		Application No.	Applicant(s)					
		10/624,357	LUKAS ET AL.	m				
Office Action Summary		Examiner	Art Unit					
		David S. Blum	2813					
	The MAILING DATE of this communication ap			ess				
Period for	or Reply							
WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLICHEVER IS LONGER, FROM THE MAILING DISTRICT OF THE MAILING DISTRICT	DATE OF THIS COMMUNI 136(a). In no event, however, may a will apply and will expire SIX (6) MOI te, cause the application to become A	CATION. reply be timely filed NTHS from the mailing date of this comm BANDONED (35 U.S.C. § 133).					
Status								
1)	Responsive to communication(s) filed on 14 L	December 2005						
·		s action is non-final.						
3)	· _							
-,_	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Dispositi	on of Claims	•						
4) 🛛	Claim(s) 30 and 31 is/are pending in the appli	ication.						
	4a) Of the above claim(s) is/are withdrawn from consideration.							
	5) Claim(s) is/are allowed.							
6)⊠	6)⊠ Claim(s) <u>30 and 31</u> is/are rejected.							
7)	Claim(s) is/are objected to.							
8)[Claim(s) are subject to restriction and/o	or election requirement.						
Applicati	on Papers							
9)	The specification is objected to by the Examina	er.						
10)⊠ The drawing(s) filed on <u>21 July 2003</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.								
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).								
	Replacement drawing sheet(s) including the correct	ction is required if the drawing	(s) is objected to. See 37 CFR	1.121(d).				
11)	The oath or declaration is objected to by the E	xaminer. Note the attached	d Office Action or form PTO-	152.				
Priority ι	ınder 35 U.S.C. § 119							
	Acknowledgment is made of a claim for foreign All b) Some * c) None of:		§ 119(a)-(d) or (f).					
	1. Certified copies of the priority documen		antindin Na					
	2. Conjugate the partition conjugate the partition		· · · — — —					
	 Copies of the certified copies of the price application from the International Burea 	·	received in this National Sta	age				
* 5	See the attached detailed Office action for a list	, , , , , , , , , , , , , , , , , , , ,	received					
			1000,100					
Attach	Wal							
Attachmen	t(s) e of References Cited (PTO-892)	4) 🔲 Intentious	Summary (PTO-413)					
2) 🔲 Notic	e of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Date					
	nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 r No(s)/Mail Date) 5)	nformal Patent Application (PTO-15	52)				
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This action is in response to the RCE filed 12/14/05.

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 30-31 are rejected under 35 U.S.C. 103(a) as being unpatentable over Mandal (2002/0142585) in view of Waldfried ("Single Wafer Rapid Curing").

Regarding claim 30, Mandal discloses a mixture for depositing an organosilicate film comprising a dielectric constant of 3.5 or below, the mixture comprising at least one structure-former precursor selected from the group consisting of an organosilane and an organosiloxane (p.3 para.29, 32-33) and a pore-former precursor (p.4 para.36).

However, Mandal does not disclose said film exhibiting an absorbance of 200 to 400 nm wavelength. Mandal would look to one such as Waldfried for a porous low-k film because Waldfried discloses wherein it is implied that at least one precursor and/or the organosilicate film exhibits an absorbance in the 200 to 400 nm wavelength range (p.226 Exp. Para.1).

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Therefore, it would have been obvious to a person of ordinary skill in the art at the time of the invention to modify Mandel by using the absorbance of Waldfried with the mixture of Mandal. The mixture of Mandal provides improved low-k material properties, and reduced process times and process temperatures (Waldfried – Abstract).

Regarding claim 31, Mandal also discloses a mixture for depositing an organosilicate film, the mixture comprising: from 5 to 95% by weight of a structure-former precursor selected from the group consisting of an organosilane and an organosiloxane and from 5 to 95% by weight of a pore-former precursor (p.3 para.29, 32-33; p.4 para.36; p.5 para.44-46).). However, Mandal does not disclose said film or precursor exhibiting an absorbance of 200 to 400 nm wavelength. Mandal would look to one such as Waldfried for a porous low-k film because Waldfried discloses wherein at least one of the precursors and/or the organosilicate film exhibits an absorbance in the 200 to 400 nm wavelength range (p.226 Exp. Para.1). Therefore, it would have been obvious to a person of ordinary skill in the art at the time of the invention to modify Mandel by using the absorbance of Waldfried with the mixture of Mandal. The mixture of Mandal provides improved low-k material properties, and reduced process times and process temperatures (Waldfried – Abstract).

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Response to Arguments

3. Applicant's arguments filed 12/14/05 have been fully considered but they are not persuasive.

The applicant argues that the (prior) action fails to provide any reason why one of ordinary skill in the art having read Mandel and Waldfried would be motivated to modify the teachings in such a way as to obtain any compound or practice any method recited in the applicant's claimed invention. The examiner disagrees. A statement as to why one of ordinary skill in the art having read Mandel and Waldfried would be motivated to modify the teachings in such a way as to obtain any compound or practice any method recited in the applicant's claimed invention has been provided.

The applicant argues that Mandel teaches only a single molecule and not a mixture of two recited components. Although Mandel teaches an example of a single molecule, Mandel (paragraph 0012) teaches the film may be deposited from "one or more compounds comprising at least one oxidizable silicon containing component and at least one non-silicon containing component...". Thus the teaching is not a single molecule but a mixture of two (or more) components.

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4. Any inquiry concerning this communication or earlier communications from the

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examiner should be directed to David S. Blum whose telephone number is (571)-272-

1687) and e-mail address is David.blum@USPTO.gov.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Carl Whitehead Jr., can be reached at (571)-272-1702. Our facsimile

number all patent correspondence to be entered into an application is (571) 273-8300.

Information regarding the status of an application may be obtained from the

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Business Center (EBC) at 866-217-9197 (toll-free).

David S. Blum

January 4, 2006